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Amendments to the Specification

Please amend the specification as follows:

Please **replace** the paragraph at page 11, lines 11-14 (paragraph 0085 of U.S. Patent Publication 2004/0027938), with the following replacement paragraph:

As shown in FIG. 5B, the lower the pit level L_p is and the higher the pit ~~ratio~~ ratio is, ~~the more increased~~ the more decreased the spherical aberration. ~~Both of a position~~ A position at which the pit ratio is maximized and ~~[[at]]~~ a position at which the spherical aberration is approximately minimized coincide with each other.